#### Note

# A Possible Rough Connection Between Aspects of the Balandin and the Volkenshtein Concepts in Heterogeneous Catalysis

Two major guidelines for interpreting and predicting the behavior of catalysts are based on the ideas put forward by Balandin (1) and Volkenshtein (2). The purpose of the present note is to point out a possible way of roughly connecting some parameters of the two conceptual approaches by considering the example of catalytic oxidations on oxide catalysts.

In the Volkenshtein's approach to catalysis (2), one invokes Fermi statistics and computes the fraction of the total number of adsorbed species held weakly or strongly (the latter being either through acceptor or donor bonds) in terms of the distances from the Fermi level to the bottom of the conduction band and to the top of the valence band. The crucial quantity is this theory, in terms of Fig. 1 (also see discussion below), is  $\Delta E_F$ .

The basic idea behind Balandin's approach (1) is that the reactants get adsorbed on the catalyst to form a surface compound and the energy of the bond between the catalyst and the reactant is related to the catalytic activity in a volcanic manner; i.e., there is a maximum in activity with increasing bond energy. In the example (oxidation) chosen here, it is generally agreed (3-5) that the bond making or breaking of interest is the enthalpy change in the reaction:

$$MO(s) \rightleftharpoons M(s) + O(g),$$
 (1)

where MO is the metal oxide; s and g denote solid and gas, respectively; M and O are metal and oxygen; the forward reaction

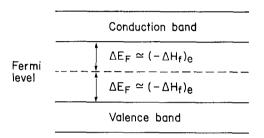


Fig. 1. A schematic representation of rough equivalence (see text) of  $\Delta E_F$  and  $(-\Delta H_f)_e$  for a catalyst.  $\Delta E_F$  is the energy gap between the Fermi level and the bottom of the conduction band (or top of the valence band) assuming the semiconducting catalyst to be intrinsic;  $(-\Delta H_f)_e$  is the negative of the heat of formation per equivalent (standard state) of the catalyst and has the significance of the energy needed to break the bond involved in the catalytic oxidation. The bond energy  $(-\Delta H_f)_e$ , is the basic parameter in Balandin's volcano plots whereas the Fermi level  $E_F$ , is the central quantity in Volkenshtein theory of catalysis; this figure, therefore, provides a rough connection between the fundamental parameters of the two theories.

represents the bond rupture whereas the backward reaction denotes the bond formation. The enthalpy change per *mole* in reaction (1), is given by:

$$\Delta H_1 = -\Delta H_f + n(\frac{1}{2}\Delta H_D), \tag{2}$$

where  $\Delta H_f$  is the heat of formation per mole of the oxide and  $\Delta H_D$  is the heat of dissociation of 1 mole of the oxygen gas to give oxygen atoms; n is the number of oxygen atoms in one molecule of the oxide. When one is considering the formation or rupture of *one* bond (instead of 1 mole) one

330 NOTE

must write the enthalpy change in reaction (1) as per bond, i.e., as per equivalent. To illustrate by example, the  $\Delta H_f$ /equiv of  $Al_2O_3$ ,  $ZrO_2$  and NiO is  $\frac{1}{6}$ ,  $\frac{1}{4}$  and  $\frac{1}{2}$ , respectively, of the corresponding  $\Delta H_f$ /mole values. By making this change in Eq. (2) and by denoting equivalent by the subscript, e, one obtains:

$$(\Delta H_1)_{\epsilon} = -(\Delta H_I)_{\epsilon} + (\Delta H_D)_{\epsilon}. \tag{3}$$

Since  $(\Delta H_D)_*$  has a constant value (=118/4=29.5 kcal) for all oxides, the enthalpy change per bond in Eq. (1), i.e., the bond energy appropriate for the present discussion (to be denoted by b(M-O) and equal to  $(\Delta H_1)_*$ ) may be written as:

$$b(M - O) = -(\Delta H_f) + K.$$
 (4)

In other words the variations in  $b\,(\mathrm{M}-\mathrm{O})$  values (to be used, e.g., in the Balandin's volcano plots for a given oxidation over a number of oxides) for various oxide catalysts are represented by the variations in the  $-(\Delta H_f)_*$  values. It is the purpose in the following discussion to show that  $-(\Delta H_f)_*$  values for oxides (or for any catalyst for that matter) are related to their Fermi level, the latter quantity being, of course, the central parameter in the Volkenshtein's theory of catalysis (2).

It has been shown previously (6, 7) that for a very large number of inorganic compounds, the following rough correlation is obeyed:

$$Eg = 2(-\Delta H_f), \tag{5}$$

where Eg is the band gap of the catalyst, oxide in the present discussion. For intrinsic semiconductors, the Fermi level may be assumed to lie at the centre of the band gap so that (8):

$$Eg = 2\Delta E_F, \tag{6}$$

where  $\Delta E_F$  is the distance (i.e., the gap) between the Fermi level and the bottom of the conduction band (or the top of the valence band) as depicted in Fig. 1. By combining Eqs. (5) and (6), we note that:

$$\Delta E_F = (-\Delta H_f)_{c}. \tag{7}$$

It follows, therefore, that the heat of

formation per equivalent  $(-\Delta H_f)_{\star}$  not only signifies the relative magnitude of the metal oxide bond energy for the various oxide catalysts, it is also related to the position of the Fermi level within the oxide. One thus obtains a connection between the basic parameter of Balandin's theory (i.e., the bond energy) and the central quantity in the Volkenshtein's theory of catalysis (i.e., the Fermi level). This arises, of course, because there exists a conceptual correlation between the solid state cohesion [represented here by the bond energy  $b \, (M - O)$  or  $-(\Delta H_f)_{\star}$ ] and semiconductivity (i.e., the band gap) of materials (6,7).

In order to avoid any possible confusion, it is necessary to further comment here on the definition of bond energy. As used in the present context, it refers to the enthalpy change in Eq. (1), in agreement with the previous usage in the literature on heterogeneous catalysis (3-5); i.e., it is the heat of formation (standard state) of the oxide plus the heat of dissociation of oxygen, both normalized, of course, appropriately as per equivalent. In the general chemical literature (9), however, the bond energy is the average strength of a bond in an oxide corresponding to the bond rupture,

$$MO(s) \rightarrow M(g) + O(g)$$
 (8)

A comparison of Eqs. (1) and (8) shows that in the former case, the metal M stays solid after the MO bond rupture (as indeed is appropriate for a catalytic reaction proceeding on an oxide) whereas in the latter case the metal M finds itself in the gas phase after the fission of the bond. The bond energy as given by Eq. (8), then, is the heat of atomization per equivalent and is represented by the enthalpy change (per equivalent) in Eq. (8)  $\Delta H_8$ , which is given by:

$$\Delta H_8 = (-\Delta H_{f_6}) + (1/4)\Delta H_D + \Delta H_{\text{sub}}/n$$
. (9)

Here,  $\Delta H_{\rm sub}$  is the heat of sublimation per *mole* of the metal atoms. Since metals generally evaporate to give atoms,  $\Delta H_{\rm sub}$  per mole is the same thing as  $\Delta H_{\rm sub}$  per atom.

In conclusion, it may be stated that the

NOTE 331

bond energy referring to Eq. (1) may be related to the Fermi level of oxides (Fig. 1).

### ACKNOWLEDGMENT

Grateful acknowledgment is made to Dr. P. Lenfant for his interest in this work.

#### REFERENCES

- Balandin, A. A., Usp. Khim. 33, 549 (1964); in "Advances in Catalysis" (W. G. Frankenburg, V. I. Kamarewsky, and E. K. Rideal, Eds.), Vol. 10, p. 96. Academic Press, New York, 1958.
- VOLKENSHTEIN, F. F., "The Electronic Theory of Catalysis on Semiconductors," Pergamon Press, New York, 1963.
- Morooka, Y., and Ozaki, A., J. Catal. 5, 116 (1966).

 MOROOKA, Y., MORIKAWA, Y., AND OZAKI, A., J. Catal. 7, 23 (1967).

- Boreskov, G. K., in "Proceedings of the Third International Congress in Catalysis" (W. M. H. Sachtler, C. G. A. Shuit and P. Zwietering, Eds.), North-Holland, Amsterdam, 1965.
- 6. Vijh, A. K., J. Phys. Chem. Solids 29, 2233 (1968).
- 7. Vijh, A. K., J. Matls. Sci. 5, 379 (1970).
- DEKKER, A. J., "Solid State Physics," Prentice-Hall, Englewood Cliffs, NJ, 1957.
- Sanderson, R. T., "Inorganic Chemistry," Van Nostrand Reinhold, New York, 1967; Howald, R., J. Chem. Ed. 45, 163 (1968).

## **А**знок **К**. Vіјн

Hydro-Quebec Institute of Research Varennes, P.Q., Canada Received May 30, 1972